

FORM PTO-1449 (SUBSTITUTE)

U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICEINFORMATION DISCLOSURE
STATEMENT BY APPLICANT
(37 CFR 1.98(b))Attorney Docket No.: GR99P3457
Appl. No.

Applicant HARALD KUHN ET AL.

Filing Date January 7, 2002
Group Art UnitJ-932 U.S. PTO
10/04/2058
01/07/02

EXAMINER INITIALS		PATENT NO.	DATE	PATENTEE	CLASS	SUB CLASS	FILING DATE
<i>MAA</i>	A	5,667,587	9/16/97	Glass et al.			
<i>MAA</i>	B	4,186,046	1/29/80	DeLai et al.			
<i>MAA</i>	C	5,895,526	4/20/99	Kitoh et al.			
	D						
	E						
	F						
	G						
	H						
	I						

FOREIGN PATENT DOCUMENT

		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUB CLASS	TRANSL. YES NO
<i>MAA</i>	J	32 30 727 C2	2/23/84	Germany			
<i>MAA</i>	K	36 44 746 a1	7/14/88	Germany			
<i>MAA</i>	L	WO 94/23096	10/13/94	WIPO			
<i>MAA</i>	M	WO 97/27350	7/31/97	WIPO			
<i>MAA</i>	N	10 291 899 A	11/4/98	Japan			

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)

<i>MAA</i>		Hofmann, D. et al.: "Use of Ta Container Material for Quality Improvement of SiC crystals grown by the Sublimation Technique", IOP Publishing Ltd, 1996, pp. 29-32;
<i>MAA</i>		Mokhov, E. et al.: "Growth of Silicon Carbide Bulk Crystals by the Sublimation Sandwich Method", Elsevier Science S.A., 1997, pp. 317-323;

EXAMINER

Matthew Anderson

DATE CONSIDERED

11/17/03

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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<i>WAL</i>	J	11 116 399	4/27/99	Japan			
<i>WAL</i>	K	11 116 398	4/27/99	Japan			
	L						
	M						
	N						

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)

<i>WAL</i>		"Tantal, Tantal-Legierung" (tantalum, tantalum alloy), Römpp Chemie-Lexikon (chemistry encyclopedia), Vol. 9, 1995, pp. 4453-4455;

EXAMINER <i>Matthew Anderson</i>	DATE CONSIDERED <i>11/17/03</i>
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